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	Class	Subclass

ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY Patent Application

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SCANNED T22	04 88	

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/994130	D	438	780	2812	C. Zuehlke

APPLICANTS

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TITLE

Novel polymers and photoresist compositions for short wavelength imaging

PTO-2040
12/88

ISSUING CLASSIFICATION

CLASS	CL. NO.	CLASS	SUBCLASS

Subsequent to _____ (Priority)	(Priority)	(Date)
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent No. _____	(Priority)	(Date)
<input type="checkbox"/> The term of _____ months of this patent have been determined.	(Legal Term)	(Date)

ISSUE FEE
ISSUE BATCH NUMBER

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